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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/618,900	07/14/2003	Akira Shimizu	ASMJP.126AUS	7366
20995	7590	05/03/2006		
KNOBBE MARTENS OLSON & BEAR LLP 2040 MAIN STREET FOURTEENTH FLOOR IRVINE, CA 92614				
			EXAMINER ZERVIGON, RUDY	
			ART UNIT 1763	PAPER NUMBER

DATE MAILED: 05/03/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

**Office Action Summary**

Application No.

10/618,900

Applicant(s)

SHIMIZU ET AL.

Examiner

Rudy Zervigon

Art Unit

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-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

**Period for Reply**

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

**Status**

- 1) ☒ Responsive to communication(s) filed on 04 April 2006.
- 2a) ☐ This action is **FINAL**. 2b) ☒ This action is non-final.
- 3) ☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

**Disposition of Claims**

- 4) ☒ Claim(s) 1-11 and 22-24 is/are pending in the application.
- 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration.
- 5) ☐ Claim(s) \_\_\_\_\_ is/are allowed.
- 6) ☒ Claim(s) 1-11 and 22-24 is/are rejected.
- 7) ☐ Claim(s) \_\_\_\_\_ is/are objected to.
- 8) ☐ Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

**Application Papers**

- 9) ☐ The specification is objected to by the Examiner.
- 10) ☒ The drawing(s) filed on 09 August 2005 is/are: a) ☒ accepted or b) ☐ objected to by the Examiner.  
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- 11) ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

**Priority under 35 U.S.C. § 119**

- 12) ☒ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
- a) ☒ All b) ☐ Some \* c) ☐ None of:
1. ☒ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

**Attachment(s)**

- |  |   |
|--|---|
| 1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)  | 4) <input type="checkbox"/> Interview Summary (PTO-413)<br>Paper No(s)/Mail Date. _____ |
| 2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)                                   | 5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)             |
| 3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)<br>Paper No(s)/Mail Date _____ | 6) <input type="checkbox"/> Other: _____  |

## **DETAILED ACTION**

### ***Continued Examination Under 37 CFR 1.114***

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on April 4, 2006, January 17, 2006 are entered.

### ***Claim Rejections - 35 USC § 103***

2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

3. Claims 1-7, 9-11, and 22-24 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hayakawa et al (USPat. 5,447,568) and Lee; Hideki (US 5,785,796 A) in view of Kajita; Akihiro et al. (US 5953634 A). Hayakawa teaches a single-wafer (3005; Figure 10; column 11, lines 41-66)-processing type CVD apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) for forming a thin film on an object (3005; Figure 10; column 11, lines 41-66) to be processed, which comprises: a reaction chamber (3006; Figure 10; column 11, lines 41-66), a susceptor (3004; Figure 10; column 11, lines 41-66) for placing said object (3005; Figure 10; column 11, lines 41-66) thereon, which is provided inside said reaction chamber (3006; Figure 10; column 11, lines 41-66); a shower plate (3502; Figure 14; column 14, lines 1-47) for emitting a jet of reaction gas (3101; Figure 10; column 11, lines 41-66) to said object (3005; Figure 10; column 11, lines 41-66), which is disposed parallel and opposing to said susceptor (3004; Figure 10; column 11, lines 41-66); an orifice (3601; Figure 10; column 11, lines 41-66) for bringing a

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liquid raw material (3101; Figure 10; column 11, lines 41-66) for deposition and a carrier gas (3002; Figure 10; column 11, lines 41-66) into said reaction chamber (3006; Figure 10; column 11, lines 41-66), which is formed through a ceiling (Figure 14; column 14, lines 1-47) of said reaction chamber (3006; Figure 10; column 11, lines 41-66); an evaporation plate (3306, Figure 11,14; column 12, lines 3-59; column 14, lines 1-47) for vaporizing said liquid raw material (3101; Figure 10; column 11, lines 41-66), which is disposed in a space between said ceiling (Figure 14; column 14, lines 1-47) of said reaction chamber (3006; Figure 10; column 11, lines 41-66) and said shower plate (3502; Figure 14; column 14, lines 1-47); said evaporation plate (3306, Figure 11,14; column 12, lines 3-59; column 14, lines 1-47) having orifice (3601; Figure 10; column 11, lines 41-66), said upper surface having pores (3362; Figure 11) unevenly distributed in the vicinity of its periphery;

and a temperature controller (4000; Figure 10; column 11, lines 41-66) for said evaporation plate (3306, Figure 11,14; column 12, lines 3-59; column 14, lines 1-47) at respective given temperatures (column 13, lines 35-45) – claim 1

Applicant's claim 1 requirement of "wherein the liquid raw material flows on the vaporization surface toward the pores" is a claim requirement of intended use of the pending apparatus claims. Further, it has been held that claim language that simply specifies an intended use or field of use for the invention generally will not limit the scope of a claim (Walter , 618 F.2d at 769, 205 USPQ at 409; MPEP 2106). Additionally, in apparatus claims, intended use must result in a structural difference between the claimed invention and the prior art in order to patentably distinguish the claimed invention from the prior art. If the prior art structure is capable of

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performing the intended use, then it meets the claim (In re Casey, 152 USPQ 235 (CCPA 1967); In re Otto, 136 USPQ 458, 459 (CCPA 1963); MPEP 2111.02).

Hayakawa further teaches:

- i. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, wherein the given temperature of said evaporation plate (3306, Figure 11, 14; column 12, lines 3-59; column 14, lines 1-47) is within the range of 40°C. to 300°C (column 13, lines 35-45), as claimed by claim 3
- ii. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, wherein said temperature controller (4000; Figure 10; column 11, lines 41-66) comprises one or more heaters (3307, 4002; Figure 11) which are arranged adjacently to said evaporation plate (3306, Figure 11, 14; column 12, lines 3-59; column 14, lines 1-47) and to said shower plate (3502; Figure 14; column 14, lines 1-47), temperature detectors (4001; Figure 11) which are respectively linked to said evaporation plate (3306, Figure 11, 14; column 12, lines 3-59; column 14, lines 1-47), a temperature regulator (4000; Figure 10) which is linked to said heater (3307, 4002; Figure 11), and said temperature detectors (4001; Figure 11) – claim 5
- iii. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, wherein said liquid raw material (3101; Figure 10; column 11, lines 41-66) is a solution wherein a metal complex raw material or a solid raw material used for deposition is dissolved in a solvent, as claimed by claim 6 – Applicant's designation of the raw material gas in a recitation of intended use of the claimed apparatus claims. It is well established that apparatus claims must be structurally distinguished from the prior art (In

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re Danley, 120 USPQ 528, 531 (CCPA 1959). "Apparatus claims cover what a device is, not what a device does ." (emphasis in original) *Hewlett - Packard Co . v. Bausch & Lomb Inc .*, 15 USPQ2d 1525, 1528 (Fed. Cir. 1990), MPEP – 2114). Further, a claim containing a "recitation with respect to the manner in which a claimed apparatus is intended to be employed does not differentiate the claimed apparatus from a prior art apparatus" if the prior art apparatus teaches all the structural limitations of the claim. *Exparte Masham*, 2 USPQ2d 1647 (Bd. Pat. App. & Inter. 1987).

- iv. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, wherein said carrier gas (3002; Figure 10; column 11, lines 41-66) is an inert gas (column 7; lines 1-3), as claimed by claim 7
- v. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, wherein the evaporation plate (3306, Figure 11, 14; column 12, lines 3-59; column 14, lines 1-47) is a hollow plate having an upper plate (Figure 14; top portion 3306) constituting the upper surface, a lower plate (Figure 14; lower portion 3306), and an interior therebetween, said upper plate (Figure 14; top portion 3306) and said lower plate (Figure 14; lower portion 3306) having pores (3362, Figure 14;) wherein the liquid raw material (3101; Figure 10; column 11, lines 41-66) flows through the pores (3362, Figure 14;) of the upper plate (Figure 14; top portion 3306), the interior, and the pores (3362, Figure 14;) of the lower plate (Figure 14; lower portion 3306) toward the shower plate (3502; Figure 14; column 14, lines 1-47), as claimed by claim 9
- vi. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 9, wherein the pores (3362, Figure 14;) of the upper plate (Figure 14; top portion

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- 3306) are arranged in the vicinity of the periphery of the upper plate (Figure 14; top portion 3306), at equal intervals (see Figure 11), as claimed by claim 11
- vii. The apparatus as claimed in claim 5, wherein the at least one heater (3307, 4002; Figure 11) is arranged exclusively downstream of the orifice (3601; Figure 10; column 11, lines 41-66), as claimed by claim 22
- viii. The apparatus as claimed in claim 9, wherein the pores (3362; Figure 11) of the upper (Figure 14; top portion 3306) and lower (Figure 14; lower portion 3306) plates are arranged concentrically (see aligned holes in Figure 10), as claimed by claim 24

Hayakawa does not teach:

- i. and a temperature controller (4000; Figure 10; column 11, lines 41-66) for controlling said shower plate (3502; Figure 14; column 14, lines 1-47) – claim 1
- ii. An evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47) having a vaporization surface facing the ceiling of the reaction chamber (3006; Figure 10; column 11, lines 41-66), having a center under the orifice (3601; Figure 10; column 11, lines 41-66), and extending toward a periphery of the shower plate (3502; Figure 14; column 14, lines 1-47) – claim 1
- iii. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, wherein a base area of said evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47) is within the range of 80% to 120% of a base area of said space, as claimed by claim 2
- iv. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 3, wherein the given temperature of said shower plate (3502; Figure 14; column 14,

- lines 1-47) is in the range of 0-50°C higher than the temperature of said evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47), as claimed by claim 4
- v. one or more cooler which are arranged adjacently to said evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47) and to said shower plate (3502; Figure 14; column 14, lines 1-47), temperature detectors which are respectively linked to said evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47) and to said shower plate (3502; Figure 14; column 14, lines 1-47), a temperature regulator which is linked to said heater, said cooler and said temperature detectors – claim 5
- vi. The apparatus (Figure 10, 11; column 11, line 41 - column 12, line 38) as claimed in claim 1, which further comprises a pressure detector for detecting a pressure in a space between the ceiling (Figure 14; column 14, lines 1-47) of said reaction chamber (3006; Figure 10; column 11, lines 41-66) and said evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47), and a pressure detector for detecting a pressure in a space between said shower plate (3502; Figure 14; column 14, lines 1-47) and said susceptor (3004; Figure 10; column 11, lines 41-66), as claimed by claim 8
- vii. The apparatus as claimed in Claim 9, wherein the number of the pores (3362, Figure 14;) of the lower plate (Figure 14; lower portion 3306) is greater than that of the upper plate (Figure 14; top portion 3306), as claimed by claim 23
- Lee teaches:
- viii. and a temperature controller (120; Figure 10; column 29, lines 12-24) for controlling Lee's shower plate (122; Figure 10; column 29, lines 12-24) – claim 1



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- ix. one or more “cooler” (123; Figure 10; column 29, lines 12-24) which are arranged adjacently to Lee’s shower plate (122; Figure 10; column 29, lines 12-24), a temperature regulator (120; Figure 10; column 29, lines 12-24) which is linked to Lee’s heater (124; Figure 10), Lee’s cooler (123; Figure 10; column 29, lines 12-24) – claim 5

Hayakawa and Lee do not teach Hayakawa’s upper plate (Figure 14; top portion 3306) of Hayakawa’s evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47) is a conical or convex surface on which Hayakawa’s liquid raw material (3101; Figure 10; column 11, lines 41-66) flows from Hayakawa’s center to Hayakawa’s periphery of Hayakawa’s upper plate (Figure 14; top portion 3306).

Kajita teaches an vaporization surface upper plate (43a; Figure 6; column 27; lines 8-65) with conical surfaces (43a; Figure 6). Kajita further teaches an evaporation plate (43a; Figure 6; column 27; lines 8-65) having a vaporization surface (43a; Figure 6) facing the ceiling of the reaction chamber (41; Figure 6), having a center (43b) under the orifice (43c), and extending toward a periphery of the shower plate (42; Figure 6) – claim 1

It would have been obvious to one of ordinary skill in the art at the time the invention was made to add Lee’s temperature control apparatus (123, 124, 120; Figure 11) to Hayakawa’s showerhead plate (3502; Figure 14), including optimizing the dimension and relative process temperature of Hayakawa’s evaporation plate (3306, Figure 11,14; column12, lines 3-59; column 14, lines 1-47) further, to add Kajita’s conical vaporizer (43; Figure 6).

Motivation to add Lee’s temperature control apparatus (123, 124, 120; Figure 11) to Hayakawa’s showerhead plate (3502; Figure 14), including optimizing the dimension and relative process temperature of Hayakawa’s evaporation plate (3306, Figure 11,14; column12, lines 3-59; column

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14, lines 1-47) further, to add Kajita's conical vaporizer (43; Figure 6) is for preventing process gas from depositing upstream of the process chamber as taught by Hayakawa (column 15; lines 42-48) and to vaporize source material without impeding flow as taught by Lee (column 25; lines 55 – column 26, line 3). It is well established that changes in apparatus dimensions are within the level of ordinary skill in the art. (Gardner v. TEC Systems, Inc., 725 F.2d 1338, 220 USPQ 777 (Fed. Cir. 1984), cert. denied, 469 U.S. 830, 225 USPQ 232 (1984); In re Rose, 220 F.2d 459, 105 USPQ 237 (CCPA 1955); In re Rinehart, 531 F.2d 1048, 189 USPQ 143 (CCPA 1976); See MPEP 2144.04). It would be obvious to those of ordinary skill in the art to optimize the operation of the claimed invention (In re Boesch, 617 F.2d 272, 205 USPQ 215 (CCPA 1980); In re Hoeschele, 406 F.2d 1403, 160 USPQ 809 (CCPA 1969); Merck & Co. Inc. v. Biocraft Laboratories Inc., 874 F.2d 804, 10 USPQ2d 1843 (Fed. Cir.), cert. denied, 493 U.S. 975 (1989); In re Kulling, 897 F.2d 1147, 14 USPQ2d 1056 (Fed. Cir. 1990), MPEP 2144.05).

4. Claim 8 is rejected under 35 U.S.C. 103(a) as being unpatentable over Hayakawa et al (USPat. 5,447,568), Lee; Hideki (US 5,785,796 A), Kajita; Akihiro et al. (US 5,953,634 A) in view of Strang, Eric J. (US 2004/0129217 A1). Hayakawa, Lee, and Ku are discussed above. Hayakawa, Lee, and Ku do not teach pressure detectors.

Strang teaches a pressure detector (220; Figure 7A,B) in his process gas delivery assembly (210) for measuring the pressure in process gas plenum 216.

It would have been obvious to one of ordinary skill in the art at the time the invention was made to add plural of Strang's pressure detector (220; Figure 7A,B) to Hayakawa's and Lee's corresponding gas delivery plenums.

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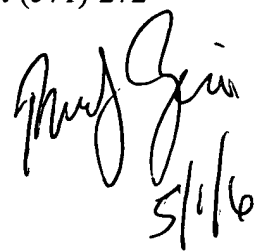
Motivation to add plural of Strang's pressure detector (220; Figure 7A,B) to Hayakawa's and Lee's corresponding gas delivery plenums is for detecting a pressure change in the process gas delivery and controlling the gas delivery in response thereof as taught by Strang (abstract).

***Response to Arguments***

5. Applicant's arguments with respect to claims 1-11, and 22-24 have been considered but are moot in view of the new grounds of rejection.

***Conclusion***

6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Rudy Zervigon whose telephone number is (571) 272-1442. The examiner can normally be reached on a Monday through Thursday schedule from 8am through 7pm. The official fax phone number for the 1763 art unit is (571) 273-8300. Any Inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Chemical and Materials Engineering art unit receptionist at (571) 272-1700. If the examiner can not be reached please contact the examiner's supervisor, Parviz Hassanzadeh, at (571) 272-1435.

  
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